

IN THE SPECIFICATION

Please amend the specification as follows:

In the abstract:

A component for a substrate processing chamber ~~comprises~~ has a structure composed of aluminum oxide. The structure has a roughened surface having a roughness average of from about 150 to about 450 microinches. A plasma sprayed ceramic coating ~~composed~~ of aluminum oxide is deposited on the roughened surface of the structure. The component may be a dome shaped ceiling of the chamber.